NOVACENTRIX

PulseForge® 1200

inspire innovate deliver

Photonic Curing Tool for Research and Development

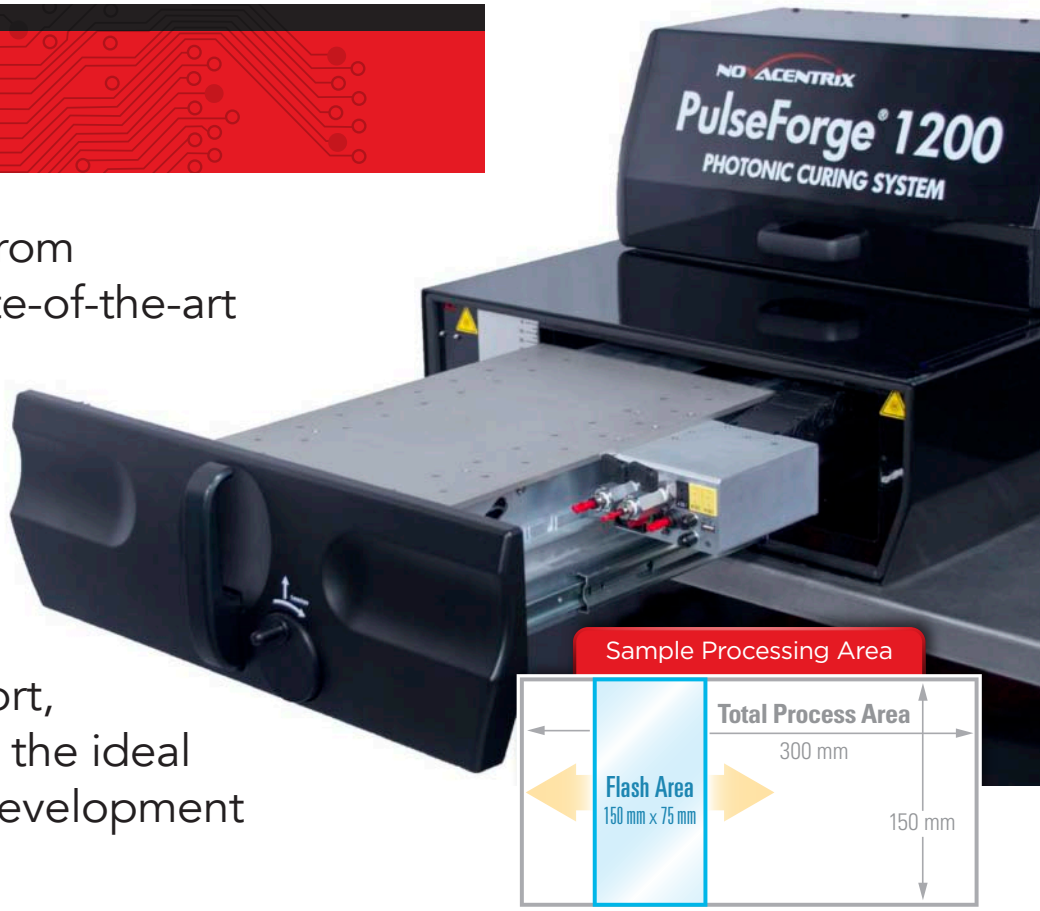
Full-Size Features in a Compact Design

Maximum Control, Minimum Time, Optimal Results

The PulseForge 1200 from NovaCentrix is the state-of-the-art photonic curing tool for research and development. Designed to reflect the experinces our own team of scientists, the PulseForge 1200 incorporates features determined to be essential for peak performance. With advanced multi-touch user interface and wide control of processing parameters, users can quickly optimize material configurations and process conditions.

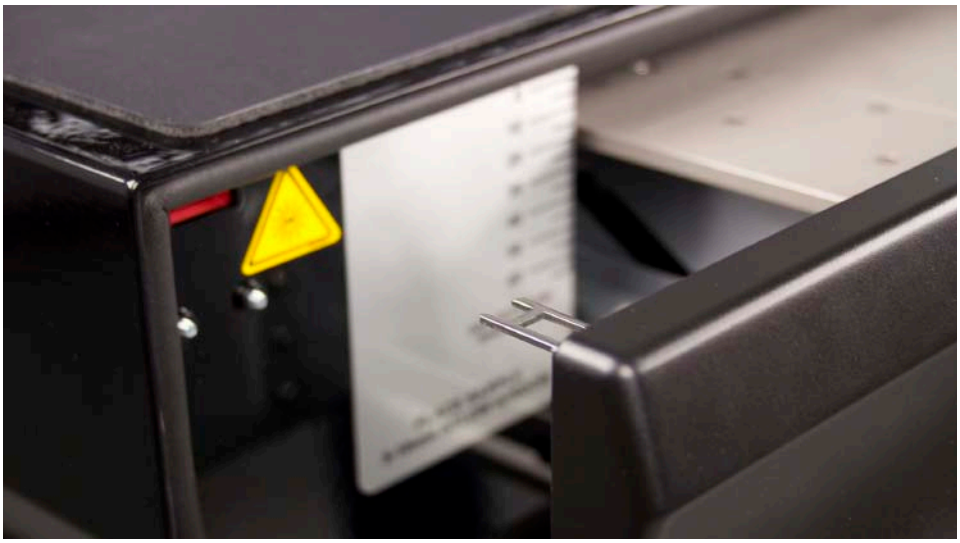
PulseForge 1200

The PulseForge 1200 from NovaCentrix offers state-of-the-art photonic curing in a low-cost, compact chassis without giving up performance or safety. Backed by world-class process engineering and support, the PulseForge 1200 is the ideal tool for research and development of printed electronics.



Engineered for Performance, Built for Use

The engineers who created the PulseForge 1200 emphasized safety throughout the design process. Some features, like the redundant optical shrouding around the lamp assembly and the multiple EMO safety pull-switches are readily apparent. Others, such as the sealed and gasketed sample processing chamber, the redundant panel/enclosure interlocks, and the numerous software system checks are less obvious.



Detail showing sealing gasket on sample processing enclosure, drawer-open interlock tab, and sample stage height indicator.

Standard Safety Features

- Fully CE Mark safety compliant.
- Safety interlocks on access panels and sample drawer: power is stopped if opened.
- Safety interlocks and indicators for cooling water: flow and conductivity.
- Obscured light path, no stray emissions.
- Status indicators on-screen.
- Isolated control volume from lamps and rest of cabinet via seals and barriers.
- Sealed drawer opening for capture and control of sample outgas products.
- HEPA-filtration of used process air.
- Output flow can be plumbed via side port.
- Air and inert gas feeds for process area or process chamber

Control What is Happening
Adjust All Production Parameters

PulseForge Software Interface

Custom Multi-Touch Operating System and Interface for Process Optimization

To control the state-of-the-art PulseForge 1200, our engineers created a state-of-the-art interface that allows users to manage and monitor all aspects of operation. Key sections include power controls with emergency stop indicator, pulse parameters, operating mode parameters, pulse profile graphic, system messages, photodiode display, and various system status and position indicators. Using the pulse settings for example enables the user to set pulse durations as short as 25 microseconds with increments as low as 1 microsecond, and pulse gaps as low as 20 microseconds with increments of 1 microsecond

Software-Configurable Pulse Modes and Pulse Shaping

Basic

Basic mode issues a single pulse at user specified length each time the machine flashes. This mode is best for curing simple nanoparticle systems with minimal drying requirements.

Pulse Shaping: Engineered Pulses Delivered Within Material Thermal Response Time

Arbitrary

Arbitrary mode allows the user to specify the individual high and low times of each µ pulse. This mode is appropriate for complex multi-layer materials, as well as creating custom thermal profiles such as millisecond-scale ramp-and-soak patterns.

Uniform

Uniform mode divides a pulse signal into a sequence of evenly-spaced µ pulses. This mode is best for processing thicker nanoparticle systems and for flake systems.

Table Height Adjustment

- Table can be raised or lowered 60mm with use of turn dial on front.
- Allows use of taller samples (not just thin sheets), variety of sample chucks (heated, vacuum), and control-volume chambers.
- For changing sample exposure intensity, use pulse control features, not the stage height adjustment, for better uniformity.

Know What is Happening
Easily Capture Process Data

Instrumentation Connections

For R&D, it is not just the results that matter, but also how to get there and what is happening to the materials along the way. That's why the PulseForge 1200 is designed and built with flexible data ports and integrated data processing for optional instrumentation accessories. The data ports provide the user the flexibility to utilize their own custom instrumentation. As a standard accessory, a bolometer for measuring the exposure energy is provided.

- Thermocouple ports x2.
- USB data port.
- BNC ports x2.
- Power plug for optional heated chuck.
- Photodiodes record each flash output.
- Built-in data acquisition card.
- Bolometer measures received energy

Pulse Delivery Timing

For research and development with photonic curing, knowing the exact exposure characteristics seen by the sample is critical. That's why all PulseForge tools are built incorporating photodiodes to measure the pulse timing. This data is presented in near-real time, after each pulse, on the touch screen display. The data is also recorded for future reference.

Bolometer test data, obtained through onboard instrumentation connections and data acquisition.

Next-Generation Bolometer

Every PulseForge 1200 includes a custom bolometer for measuring energy delivered to the processed sample. This data is also displayed on the touch screen, and the data can be exported to a user's own storage device.

- Connects to sample stage instrumentation box.
- Designed for rapid signal response.
- Compact size.
- Place on stage simultaneously with samples to measure energy received by samples on the same process run.

Table Position Indicator

- The sample table scans at up to 30 meters/minute.
- The blue LED shows the table location in the enclosure.

PulseForge 1200 Photonic Curing Tool for Research and Development

Now you can close the loop on the development process.

Integrated Power Supply and Switching

Proprietary High-Power Charging Supplies and Ultra-Rapid Switching

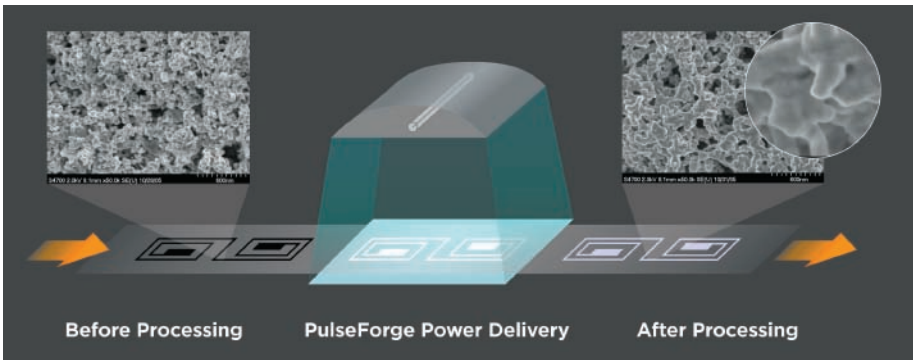
Unsatisfied with the limited capabilities of power supplies available on the market, NovaCentrix engineers developed our own. The power supplies for the PulseForge 1200 are based on those developed for the full-size PulseForge tools, ensuring the scalability of results obtained with the R&D-scale equipment. By building them to a standard size format, they can be easily upgraded or updated to remain state-of-the-art.

Easy-Access Connections

- Signal outputs from sample stage instrumentation.
- Flow controllers for adjustment of cooling air and inert purge.

What is Photonic Curing?

Photonic curing is the high-temperature thermal processing of a thin film using pulsed light from a flashlamp. When this transient processing is done on a low-temperature substrate such as plastic or paper, it is possible to attain a significantly higher temperature than the substrate can ordinarily withstand under an equilibrium heating source such as an oven. Since the rate of most thermal curing processes (drying, sintering, reacting, annealing, etc.) generally increase exponentially with temperature (i.e. they obey the Arrhenius equation), this process allows materials to be cured much more rapidly (in about 1 millisecond) than with an oven taking seconds to minutes. Photonic curing not only allows a dramatic increase in the processing speed, but it also enables the creation of new materials not possible with an ordinary oven as certain limitations of equilibrium thermal processing are eliminated.



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